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# A Study of the Sensitivity of Energy Conversion Efficiency to Load Variation in Class-E Resonant Power Inverter 

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# A STUDY OF THE SENSITIVITY OF ENERGY CONVERSION EFFICIENCY TO LOAD VARIATION IN CLASS-E RESONANT POWER INVERTER 

by<br>Richard Samuel Jennings<br>B.S. December 2012, West Virginia University<br>A Thesis Submited to the Faculty of Old Dominion University in Partial Fulfillment of the Requirements for the Degree of<br>MASTER OF SCIENCE<br>ELECTRICAL AND COMPUTER ENGINEERING<br>OLD DOMINION UNIVERSITY<br>May 2017

Approved by:<br>Yucheng Zhang (Director)<br>Isaac Flory (Member)<br>Shu Xiao (Member)

# ABSTRACT <br> A STUDY OF THE SENSITIVITY OF ENERGY CONVERSION EFFICIENCY TO LOAD VARIATION IN CLASS-E RESONANT POWER INVERTER 

Richard Samuel Jennings

Old Dominion University, 2017
Director: Dr. Yucheng Zhang
In this thesis the sensitivity of energy conversion efficiency (ECE) and output power of a class-E resonant inverter under variable resistive and inductive load assignments is examined for wireless power transfer (WPT) applications. By performing simulation and mathematical analysis, it was found that the on-resistance of the switching device has minor effect on the design's efficiency. Additional comparisons between the simulation and mathematical analysis show reasonable output power and ECE load variation performance for the design, but with unique load impedances where zero voltage switching (ZVS) and zero derivative switching (ZDS) are achieved. These comparisons also expose inaccurate mathematical assumptions. Experimental test results are presented to validate simulation and mathematical assumptions. These tests also show invalid assumptions used in the simulation and mathematical analysis and the performance of the class-E resonant power inverter suffer due to the difference in resonant frequencies during switch on and off state periods, nonlinear shunt capacitance, and parasitic impedances.

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## NOMENCLATURE

| C | Capacitance of resonant tank |
| :---: | :---: |
| $\mathrm{C}_{1}$ | Shunt capacitance |
| D | Duty cycle of $\mathrm{Q}_{1}$ |
| $\mathrm{D}_{1}$ | Equals (1-D) used for simplifying mathematic notation |
| ECE | Energy conversion efficiency |
| EV | Electric vehicle |
| $\mathrm{f}_{\mathrm{r}, \mathrm{A}}$ | Resonant frequency defined in circuit loop A (Figure 2) during on and off states of |
|  | Q1 |
| $\mathrm{fr}, \mathrm{B}$ | Resonant frequency defined in circuit loop B (Figure 3) during on and off states of |
|  | $\mathrm{Q}_{1}$ |
| $\mathrm{fr}_{\mathrm{r}, \mathrm{Con}}$ | Resonant frequency defined in circuit loop C (Figure 4) during on-state of $\mathrm{Q}_{1}$ |
| $\mathrm{fr}_{\mathrm{r}, \mathrm{Coff}}$ | Resonant frequency defined in circuit loop C (Figure 4) during off-state of $\mathrm{Q}_{1}$ |
| fsw | Switching frequency of $\mathrm{Q}_{1}$ |
| GaN | Gallium-nitride |
| IdD | Supply current amplitude |
| IGBT | Insulated bipolar transistor |
| Io | Amplitude of output current |
| $\mathrm{I}_{\mathrm{O}, \mathrm{RMS}}$ | RMS of output current |
| io | Load current waveform |
| is | Current through $\mathrm{C}_{1}$ during the off-state of $\mathrm{Q}_{1}$ and through $\mathrm{Q}_{1}$ during the on-state |
|  | of $\mathrm{Q}_{1}$ |
| KCL | Kirchhoff's current law |


| KVL | Kirchhoff's voltage law |
| :---: | :---: |
| $\mathrm{L}_{\mathrm{F}}$ | Choke Inductor |
| L1 | Load inductance |
| L | Inductance of resonant tank |
| MOSFET | Metal oxide semiconductor field-effect transistor |
| PCB | Printed circuit board |
| PF | Power factor |
| $\mathrm{P}_{0}$ | Active power on load |
| PWM | Pulse width modulation |
| QL | Quality factor of resonant tank |
| Q1 | Switching MOSFET |
| R | Load resistance |
| $\mathrm{R}_{\mathrm{DS} \text { (on) }}$ | On-resistance of $\mathrm{Q}_{1}$ |
| RMS | Root mean square |
| Si | Silicon |
| SiC | Silicon-carbide |
| $\mathrm{V}_{\mathrm{DD}}$ | Voltage of DC supply |
| $\mathrm{V}_{\text {DS }}$ | Drain-source voltage of MOSFET |
| V | Voltage across switch $\mathrm{Q}_{1}$ |
| $\mathrm{V}_{\mathrm{O}}$ | Output voltage amplitude |
| Vo,RMS | Output voltage RMS |
| X | Reactance of resonant tank |
| WPT | Wireless power transfer |

Z Load impedance
ZDS Zero-derivative switching of $\mathrm{Q}_{1}$ at turn-on
Zopt $\quad$ Optimum load impedance when both ZVS and ZDS are realized on $\mathrm{Q}_{1}$
ZVS Zero-voltage switching of $\mathrm{Q}_{1}$ at turn-on
$\Phi$
Phase difference between load voltage and load current
$\omega$
Angular switching frequency (rad/sec)

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## CHAPTER 1

## INTRODUCTION

### 1.1 APPLICATION DETAILS

Electric vehicles are increasing in popularity due to their affordability and renewable energy efforts. Infrastructure is required for charging the batteries of these vehicles. Traditionally electric vehicle (EV) battery charging has been accomplished by establishing an electrical cable connection between the charger infrastructure and vehicle. User inconvenience and the required maintenance associated with EV charging raise concerns with this approach due to the frequency of when these vehicles need charged. This has sparked interest in the use of wireless power transfer (WPT) technologies to allow battery charging during vehicle movement or parking without cable connections between charging infrastructure and vehicle.

Traditional EV charging systems will always be more efficient than WPT systems because of air conductivity properties. In order for the interest of WPT systems to be realized in the consumer market, the benefits of WPT must outweigh the disadvantage of the added inefficiency and the efficiency of market available WPT systems must increase. Notable state of the art WPT systems, outlined below, show promise of this aspect but opportunity for improvement is available. The transmitter topologies used in these systems are noted when known to provide consideration on the design trade-offs between transmission frequency and power switching losses of the transmitter circuit.

- A $12 \mathrm{~kW}, 22 \mathrm{kHz}, 95.136$ percent DC-to-DC efficient WPT system was integrated into a Toyota RAV4 by researchers from the Oak Ridge National Laboratory. A full-bridge inverter was used to create the transmission signal using SiC DMOS power devices. The
transmission efficiency of this system was 98.599 percent [1].
- A $3.3 \mathrm{~kW}, 19.5 \mathrm{kHz}, 87$ percent DC-to-DC efficient WPT system, called the PLUGLESS ${ }^{\mathrm{TM}}$ Level 2 EV Charging System, was manufactured by Evatran Group Incorporated for charging the Chevrolet Volt and the Nissan LEAF.
- A $50 \mathrm{~kW}, 85 \mathrm{kHz}, 95.8$ percent DC-to-DC efficient WPT system was established by researchers Roman Bosshard and Johann Kolar. A full-bridge inverter was used to create the transmission signal using $1.2 \mathrm{kV} \mathrm{SiC} \mathrm{MOSFET} \mathrm{power} \mathrm{devices}$. efficiency of this system was 98 percent [2].
- A simulated $5 \mathrm{~W}, 5 \mathrm{MHz}, 30 \mathrm{~cm}$ coil distance, 65.9 percent DC-to-DC efficient WPT system was established and documented in simulation results in. A class-E resonant inverter was used to create the transmission signal using power MOSFETs [3].
- A $295 \mathrm{~W}, 134 \mathrm{kHz}, 75.7$ percent DC-to-DC efficient WPT system. A class-E resonant inverter was used to create the transmission signal using HEXFET power MOSFETs [4]. In addition to air coupling power losses, WPT power system losses are comprised of passive materials of the transmitter and receiver coils and the associated power electronics for sending and receiving power in a useful manner. Increasing the transmission frequency is the most viable method to decrease total system power losses by increasing the concentration of magnetic flux lines between the transceiver and receiver. However, there is a limit to which increased design switching frequency causes other prohibitive parasitic effects and associated power losses in the power electronics and core materials [2]. This is shown in the mentioned state of art work with 85 kHz as the limit which was achieved using a full-bridge inverter. Researchers who published [3] and [4] selected the class-E resonant inverter topology for
transmitter research above 85 kHz because of its capability to operate with zero voltage and zero derivative switching to achieve higher efficiency than full-bridge inverter and other available topologies. The associated results of their research showed that the parasitic effects at higher frequency cause poorer WPT system efficiency compared to work in [2] and the need for additional research. The focus of this research begins with identifying or confirming the class-E resonant inverter as the most effective circuit topology that may be used in WPT high frequency transmitter applications.

Resonant inverters are the best suited for high frequency transmitter WPT applications because they offer relatively high efficiency and power density by operating at high frequency with zero voltage switching (ZVS) and zero derivative switching (ZDS) when compared to traditional inverters. ZVS and ZDS conditions can drastically reduce power switching losses by only changing a switch state when the voltage drop equals zero (ZVS) and with no rate of change (ZDS). A major constraint resonant inverters have is maintaining their ZVS and ZDS performance during load variation. Modern WPT systems must perform well during these conditions for varying the EV charge rate in an electric grid demand response event. Even slight load variation of these topologies from their optimum designed load impedances will degrade several key factors in system performance, such as the output active power and the energy conversion efficiency (ECE).

One method to reduce the negative effects of load variation is to utilize resonant circuit topologies with fewer switching devices, such as the class-E resonant inverter and its derivative topologies, for transmitter applications. The class-E resonant inverter offers up to 2.847 times more the output power capability of the popular class-D resonant inverter when using the same supply voltage but with up to 3.562 times higher breakdown voltage [4]. Also, the class-E
topology has one less switch than the class-D topology which is ideal to avoid poor load variation performance. The class-E topology has been known for decades and been limited from use because of the lack of feasible semiconductors to handle higher imposed voltage stress caused by fewer switching devices. However, the performance of semiconductors has greatly improved over the recent decades opening new possibilities. In addition, ongoing research and development in gallium nitride $(\mathrm{GaN})$ and silicon carbide $(\mathrm{SiC})$ materials offers promise to further improve power semiconductor temperature, efficiency and voltage breakdown performance [5], [6].

The class-E resonant inverter was first invented by Alan D. Sokal in 1975 for a highefficiency, single switch RF power amplifier [7]. It achieves high-efficiency (e.g., 96 percent) by using a single switching device capable of high voltage stress and soft switching [8]. In addition to RF power amplifier applications, this topology is used in applications such as high-frequency electronic lamp ballasts [9], [10], cellular telecommunications [11], plasma heating [12], DC-DC converter [13], high-power-factor [14], microwave power [15], induction heating [16], implant electronic instruments [16] and WPT [4], [17]. In 1989, Marian K. Kazimierczuk and Jacek J. Jozwik studied the relationship between the relative bandwidth and load resistance for a class-E resonant inverter. The outcome of this work was the introduction of the class- $\mathrm{E}^{2}$ topology which included a class-E rectifier on the load side of the class-E topology [18]. The class- $\mathrm{E}^{2}$ topology has recently been applied to wireless power transfer applications using SiC and GaN switching devices [19]. The class- $\Phi$ and class- $\Phi 2$ topologies were also derived from the class-E topology and involve a single power switch. They were developed to maintain low voltage stress on components, provide small passive energy storage and to improve system efficiency, reliability and power density. Applications for the class- $\Phi$ and class- $\Phi 2$ topologies include electric vehicles, energy harvesting, and modern telecommunication power systems [20], [21], [22].

Similar to other resonant power inverters and converters, the output power and ECE of the class-E resonant inverter and its derivative topologies are still strongly affected by load assignment. Previous research on these topologies have provided equations for calculating the output active power and the ECE within and outside of nominal conditions [16], [23], [24], [25] and performed design and analysis for an optimum load assignment achieving soft switching [15], [26], [27], [28]. However, the previous known research only shows the power and ECE sensitivity of a specific design to variable load assignments operating with less than five watts [25]. Understanding these sensitivities at higher output power designs is important to understand the flaws of existing analytical design procedures, to better understand parasitic and nonlinear effects caused by high frequency switching operation, and to aid in producing better circuit designs and optimal control in the class-E topologies.

### 1.2 THESIS OBJECTIVES

Class-E resonant inverters used in WPT transmitter applications have proven to contribute to a less efficient overall system than WPT applications employing full bridge inverters. However, the class-E resonant inverter shows promise of replacing the full bridge inverter in WPT applications to improve overall system efficiency. The aim of this research is to provide contributions to a realizable, compact and efficient class-E resonant inverter that could be used in WPT transmitter applications. This will be accomplished by describing the class-E resonant inverter in Chapter 2, introducing a class-E resonant inverter design in Chapter 3, and simulationally, mathematically, and experimentally analyzing its ECE and output power sensitivity to load variation in Chapters 4,5 and 6, respectively. The design specifications include $208 \mathrm{~V}_{\mathrm{DC}}$ input voltage, 1 MHz switching frequency, and 150 W power output. Notably, the switching frequency of 1 MHz is chosen to push the limits of existing work that has been performed in this area. Chapter 7 will provide the conclusion of this work and recommendations for future work.

## CHAPTER 2

## DESCRIPTION OF THE CLASS-E RESONANT INVERTER TOPOLOGY

### 2.1 SCHEMATIC AND DEFINITION OF CIRCUIT LOOPS

The schematic of the class-E resonant inverter topology is shown in Figure 1. Figures 2,
3, and 4 define names for the three main circuit loops of the topology used for analysis.


Figure 1 Schematic of the class-E resonant inverter


Figure 2 Circuit loop A defined


Figure 3 Circuit loop B defined


Figure 4 Circuit loop C defined

### 2.2RESONANT FREQUENCIES

Four different resonant frequencies exist within the circuit and the way they are designed has a significant impact on the circuit performance. During the on and off states of $\mathrm{Q}_{1}$ a resonant frequency is generated from circuit elements $\mathrm{L}_{\mathrm{F}}, \mathrm{L}, \mathrm{C}$ and $\mathrm{L}_{1}$ within circuit loop A as defined in Equation (2.2.1).

$$
\begin{equation*}
f_{r, \mathrm{~A}}=\frac{1}{2 \pi \sqrt{\left(L_{F}+L+L_{1}\right) C_{1}}} \tag{2.2.1}
\end{equation*}
$$

During only the on-state of $\mathrm{Q}_{1}$ a resonant frequency is generated from circuit elements L and C within circuit loop C as defined in Equation (2.2.2).

$$
\begin{equation*}
f_{r, C_{\mathrm{on}}}=\frac{1}{2 \pi \sqrt{\mathrm{LC}}} \tag{2.2.2}
\end{equation*}
$$

During only the off-state of $\mathrm{Q}_{1}$ circuit elements $\mathrm{L}_{\mathrm{F}}$ and $\mathrm{C}_{1}$ within circuit loop B generate a resonant frequency as defined in Equation (2.2.3) and circuit elements $\mathrm{C}_{1}, \mathrm{~L}, \mathrm{C}$ and $\mathrm{L}_{1}$ within circuit loop C generate a resonant frequency as defined in Equation (2.2.4).

$$
\begin{gather*}
f_{r, \mathrm{~B}}=\frac{1}{2 \pi \sqrt{L_{F} C_{1}}}  \tag{2.2.3}\\
f_{r, C_{\text {off }}}=\frac{1}{2 \pi} \sqrt{\frac{1+\frac{C_{1}}{C}}{\left(L+L_{1}\right) C_{1}}} \tag{2.2.4}
\end{gather*}
$$

### 2.3 LOAD DEFINITION

The load is defined as, Z , in Equation (2.3.1). Load resistance, R , and inductance, $\mathrm{L}_{1}$, may be calculated according to Equations (2.3.2) and (2.3.4), respectively. An optimum load, Zopt, exists where ZVS and ZDS requirements are satisfied.

$$
\begin{gather*}
Z=R+j \omega L_{1}  \tag{2.3.1}\\
R=Z \times P F  \tag{2.3.2}\\
X_{L}=\sqrt{\left(\frac{R}{P F}\right)^{2}-R^{2}} \tag{2.3.3}
\end{gather*}
$$

$$
\begin{equation*}
L_{1}=\frac{2 \pi f}{X_{L}} \tag{2.3.4}
\end{equation*}
$$

Three regions of load operation are defined: 1.) $\mathrm{Z}<\mathrm{Z}_{\mathrm{OPT}} 2$.) $\mathrm{Z}=\mathrm{Z}_{\mathrm{OPT}}$ and 3.) $\mathrm{Z}>\mathrm{Z}_{\mathrm{OPT}}$. In Region 1 , reduction of impedance causes decreased damping of $V_{S}$ beneath zero volts before $\mathrm{Q}_{1}$ turns on. In practice when a MOSFET is utilized, the intrinsic reverse body diode of the switching device is activated effectively reducing the switch voltage to zero instead of a negative value. While ZVS may seem in effect in Region 1 due to reverse body diode voltage, it is impossible to achieve ZDS at turn-on transient, resulting in increased power switching losses. In Region 2, Z ${ }_{\mathrm{OPT}}$ triggers the exact damping of $\mathrm{V}_{\mathrm{S}}$ required at $f_{r, C_{o f f}}$ to achieve ZVS and ZDS simultaneously. In Region 3, an increased impedance causes over-damping of $\mathrm{V}_{\mathrm{S}}$ and thus, during the turn-on process of $\mathrm{Q}_{1}$, neither ZVS nor ZDS can be realized. A visual concept of the three defined impedance regions is shown in Figure 5 below.


Figure 5 Three regions of load operation for the class-E topology using MOSFET as switching device

### 2.4 CHOKE INDUCTOR, $L_{F}$

The primary purpose of the choke inductor, $\mathrm{L}_{\mathrm{F}}$, is to limit oscillation of $\mathrm{I}_{\mathrm{DD}}$ to protect the frontier DC voltage source and improve power quality. Figure 6 shows the effect of $L_{F}$ on $I_{D D}$ when all other circuit elements than $L_{F}$ remain constant. Often in practice these positive and negative amplitudes are required to be within five percent of each other. As described in Equation (2.4.1), the increase of switching frequency, $\mathrm{f}_{\mathrm{SW}}$, in $\mathrm{Q}_{1}$ would reduce the inductance of $\mathrm{L}_{\mathrm{F}}$, which is required to achieve the same impedance $X_{L_{F}}$ to meet the design criteria of five percent current oscillation.

Increased choke inductance causes decreased $\mathrm{V}_{\mathrm{S}}$ and $\mathrm{P}_{\mathrm{O}}$ capability. Figure 7 shows the effect of $L_{F}$ on $P_{O}$ and $V_{S}$ when all other circuit elements than $L_{F}$ remain constant. $L_{F}$ should therefore be designed to limit $\mathrm{I}_{\mathrm{DD}}$ oscillation while limiting the maximum amplitude of $\mathrm{V}_{\mathrm{S}}$ to capability of the selected switching device and allowing the required power output.

$$
\begin{equation*}
X_{L_{F}}=2 \pi f_{S W} L_{F} \tag{2.4.1}
\end{equation*}
$$



Figure $6 \mathrm{I}_{\mathrm{DD}}$ comparison of design with low $\mathrm{L}_{\mathrm{F}}$ inductance and high $\mathrm{L}_{\mathrm{F}}$ inductance


Figure $7 \mathrm{P}_{\mathrm{O}}$ and $\mathrm{V}_{\mathrm{S}}$ comparison of design with low $\mathrm{L}_{\mathrm{F}}$ inductance and high $\mathrm{L}_{\mathrm{F}}$ inductance

### 2.5 LC RESONANT TANK CIRCUIT

The purpose of inductor, $L$, and capacitor, $C$, is to establish $f_{r, C o n}$ and $f_{r, \text { Coff }}$ near the switching frequency, fsw. This under-damped circuit establishes Io and portrays a sinusoidal switch voltage which allows $\mathrm{C}_{1}$ to controllably charge and discharge during the off state of $\mathrm{Q}_{1}$ so that ZVS and ZDS may be achieved. The description of how under-damped the oscillation may be described by the load quality factor, or $\mathrm{Q}_{\mathrm{L}}$, according to Equation (2.5.1). A higher $\mathrm{Q}_{\mathrm{L}}$ allows a lower rate of energy loss but is less effective for a wide range of frequencies. This allows oscillations to occur longer with less dampening. However, a higher $\mathrm{Q}_{\mathrm{L}}$ causes more stress on circuit components.

$$
\begin{equation*}
Q_{L}=\frac{2 \pi f_{S W}\left(L+L_{1}\right)}{R} \tag{2.5.1}
\end{equation*}
$$

### 2.6 SHUNT CAPACITANCE, $\mathrm{C}_{1}$

The shunt capacitance, $\mathrm{C}_{1}$, enables designed control of $\mathrm{V}_{\mathrm{S}}$ to realize ZVS and ZDS during the switch transition from off-state to on-state. It also establishes $\mathrm{f}_{\mathrm{r}, \mathrm{Coff}}$ during the off-state of the switch such that $f_{S W}$ is between $f_{r, C o n}$ and $f_{r, \text { Coff }}$. The difference between $f_{r, \text { Con }}$ and $f_{r, \text { Coff }}$ contributes to impurity of the $I_{0}$. To reduce this impurity, $C_{1}$ should be minimized so that $f_{r, C o n}$ and $f_{r, \text { Coff }}$ can be as closely related as possible to $\mathrm{f}_{\text {Sw }}$.

### 2.7 SWITCH DUTY CYCLE, D

The switch duty cycle contributes to the class-E circuit's output power, efficiency, and voltage stress on $\mathrm{Q}_{1}$. Larger duty ratios offer the highest efficiency but with reduced circuit power output capability and increased voltage stress on $\mathrm{Q}_{1}$. Smaller duty ratios offer less circuit efficiency but with less voltage stress on $\mathrm{Q}_{1}$. Duty cycles within the 0.35 to 0.65 range offer the optimum operating point considering maximum power output capability, voltage stress on $\mathrm{Q}_{1}$, efficiency. The highest power output capability is when $\mathrm{D}=0.5$ [27], [29], [30]. Circuit components may be tuned to allow ZVS and ZDS operation based on the duty cycle chosen.

## CHAPTER 3

## DESIGN OF A CLASS-E RESONANT INVERTER

### 3.1 BASIC REQUIREMENTS

A voltage supply, $\mathrm{V}_{\mathrm{DD}}$, of 208 V was chosen based on its acceptance in modern data center and electric vehicle charging applications. The switching frequency was chosen as 1 MHz in aim to achieve higher power density and provide a more efficient transmitter frequency than modern WPT systems. Target output power was defined at 150 W with the goal to realize an experimental test bed and provide a reference point for future work to achieve higher power output using the 208 V supply voltage.

### 3.2 BRUTE FORCE MATHEMATICAL DESIGN PROCEDURES

The class-E circuit topology can be described by a group of the second order differential equations shown in Equations (3.2.1), (3.2.2), (3.2.3), and (3.2.4). These equations are derived using KCL and KVL for the nodes and loops within the circuit. Solving these equations to determine component values requires brute force analytical techniques using the class-E optimum conditions as no such explicit solution has yet been known to be discovered.

During the on-state of $\mathrm{Q}_{1}$,

$$
\begin{gather*}
V_{D D}-I_{D D_{o n}}(t) R_{D S(o n)}+I_{O} R_{D S(o n)} \cos (\omega t+\phi)=L_{F} \frac{d^{2} I_{D D_{o n}}(t)}{d t^{2}}  \tag{3.2.1}\\
C_{1} \frac{d^{2} V_{S_{o n}}(t)}{d t^{2}}+\frac{1}{R_{D S(o n)}} \frac{d V_{S_{o n}}(t)}{d t}-\frac{V_{D D}-V_{S_{o n}}(t)}{L_{F}}-\omega I_{O} \cos (\omega t+\phi)=0 \tag{3.2.2}
\end{gather*}
$$

During the off-state of $\mathrm{Q}_{1}$ :

$$
\begin{equation*}
L_{F} C_{1} \frac{d^{2} I_{D D_{o f f}}(t)}{d t^{2}}+I_{D D_{o f f}}(t)=I_{O} \cos (\omega t+\phi) \tag{3.2.3}
\end{equation*}
$$

$$
\begin{equation*}
L_{F} C_{1} \frac{d^{2} V_{S_{o f f}}(t)}{d t^{2}}+V_{S_{o f f}}(t)-V_{D D}-\omega L_{F} I_{O} \cos (\omega t+\phi)=0 \tag{3.2.4}
\end{equation*}
$$

In this work, no solution was found using brute force techniques based on Equations (3.2.1), (3.2.2), (3.2.3), and (3.2.4) with class-E conditions. Other researchers have had similar results using brute force techniques [26], [27]. Ideally, no assumptions are made in the design for increased accuracy and performance. Because the scope of this work is to examine load sensitivity, the design will be established using assumptions and simulation validation.

### 3.3 ASSUMPTIONS USED TO SIMPLIFY DESIGN PROCEDURE

The $\mathrm{Q}_{1}$ duty cycle was chosen as 0.45 to optimize the performance of the circuit and limit the maximum amplitude $\mathrm{V}_{\text {S }}$ to device capabilities [30]. The load resistance was chosen as $100 \Omega$ for PF 1.0 load. The design requires the ripple of the input current to be less than five percent of its RMS value. The selection of $L_{F}$ according to Equation (3.3.1) presented within [16] was causing more than desirable current ripple. To simplify the design, choke inductor, $\mathrm{L}_{\mathrm{F}}$, was selected as 1.5 mH , which is approximately two times the inductance suggested in [16].

$$
\begin{equation*}
L_{F}=\frac{7 R}{f} \tag{3.3.1}
\end{equation*}
$$

In summary, the component values are as described in the table below, which were used in the design procedure to be presented.

Table 1 Summary of design values defined and assumed

| $\mathrm{V}_{\mathrm{DD}}$ | 208 V |
| :--- | :--- |
| $\mathrm{~F}_{\mathrm{SW}}$ | 1 MHz |
| D | 0.45 |
| $\mathrm{P}_{\mathrm{O}}$ | 150 W |
| $\mathrm{~L}_{\mathrm{F}}$ | 1.5 mH |


| $\mathrm{Q}_{\mathrm{L}}$ | 6 |
| :--- | :--- |
| R | $100 \Omega$ |

### 3.4DESIGN PROCEDURE

The key assumptions used with this approach were the following [23], [29]:

1) $L_{F}$ is large enough to neglect its current ripple.
2) Internal resistance of $L_{F}$ is zero and the $D C$ voltage drop across $L_{F}$ is zero.
3) $Q_{L}$ of the resonant circuit is high enough so that the output current can be considered as a pure sinusoidal wave.
4) Load resistance includes parasitic resistances of the resonant circuit such that the resonant circuit is considered as a pure reactance.
5) Internal resistance of the switching device is neglected and equal to zero.
6) Turn-on and turn-off times of switching device are neglected and as a result $\mathrm{Q}_{1}$ turns on and off instantly.
7) ZVS and ZDS conditions are satisfied.
8) $C_{1}$ is constant and not influenced by other parameters.

Equations (3.4.1) through (3.4.11) were used to select component values shown in Table 2. While the load resistance was predefined already in Table 1, Equation (3.4.2) was still used when selecting dependent component values. Figure 8 shows the mathematical defined $\mathrm{V}_{\mathrm{S}}$ using Equation (3.4.11) and component values shown in Table 2. These results validate ZVS and ZDS conditions were satisfied according to mathematical analysis.

$$
\begin{equation*}
\phi=\tan ^{-1}\left[\frac{\cos (2 \pi D)-1}{2 \pi(1-D)+\sin (2 \pi D)}\right]+n \pi \tag{3.4.1}
\end{equation*}
$$

$$
\begin{align*}
& R=2 \frac{V_{D D}^{2} \sin ^{2}(\pi D) \sin ^{2}(\pi D+\phi)}{\pi^{2}(1-D)^{2} P_{O}}  \tag{3.4.2}\\
& C_{1}=\frac{P_{O}(1-D) \cos (\pi D+\phi)[\pi(1-D) \cos (\pi D)+\sin (\pi D)]}{\omega V_{D D}{ }^{2} \sin (\pi D+\phi) \sin (\pi D)}  \tag{3.4.3}\\
& L=\frac{Q_{L} R}{\omega}  \tag{3.4.4}\\
& a_{1}=\cos (2 \pi D)-\pi(1-D) \sin (2 \pi D)  \tag{3.4.5}\\
& a_{2}=(1-D) \pi \cos (\pi D)+\sin (\pi D)  \tag{3.4.6}\\
& L_{b}=\frac{R}{\omega} \frac{2(1-D)^{2} \pi^{2}-1+2 \cos \phi \cos (2 \pi D+\phi)-\cos (2 \pi D+2 \phi) a_{1}}{4 \sin (\pi D) \cos (\pi D+\phi) \sin (\pi D+\phi) a_{2}}  \tag{3.4.7}\\
& C=\frac{1}{\omega^{2}\left(L-L_{b}\right)}  \tag{3.4.8}\\
& b_{1}=\frac{V_{D D} \tan (\pi D+\phi) \sin (\pi D)}{(1-D)[\pi(1-D) \cos (\pi D)+\sin (\pi D)]}  \tag{3.4.9}\\
& b_{2}=\frac{2 \pi(1-D)[\cos (\omega t+\phi)-\cos (2 \pi D+\phi)]}{\cos (2 \pi D+\phi)-\cos \phi}  \tag{3.4.10}\\
& V_{s}=b_{1}\left(\omega t-2 \pi D+b_{2}\right) \tag{3.4.11}
\end{align*}
$$

Table 2 Summary of components calculated using information provided in Table 1 and Equations (3.4.2), (3.4.3), (3.4.4) and (3.4.8)

| $R$ | $122.13 \Omega$ |
| :--- | :--- |
| $\mathrm{C}_{1}$ | 284.94 pF |
| L | $116.62 \mu \mathrm{H}$ |
| C | 282.31 pF |



Figure 8 Validation using Equation (3.4.11) that components selected using mathematical analysis satisfy ZVS and ZDS conditions

### 3.5 SIMULATION RESULTS OF DESIGN BASED ON KAZIMIERCZUK'S DESIGN EQUATIONS

Several key mathematical assumptions were required to determine the component values listed in Table 2. This section provides simulation analysis to validate and further improve the design of these components using fewer assumptions. Assumptions are still required for this process and include:

1) $L_{F}$ is large enough to neglect its current ripple.
2) Internal resistance of $L_{F}$ is zero and the $D C$ voltage drop across $L_{F}$ is zero.
3) Internal resistance of $Q_{1}$ is considered and a non-zero value.
4) Turn-on and turn-off times of switching device are neglected and thus $\mathrm{Q}_{1}$ turns on and off instantly.
5) $C_{1}$ is constant and not influenced by other parameters.

For this analysis the metal oxide semiconductor field-effect transistor (MOSFET) was selected and modeled as the switching device because of its higher power capability at higher switching frequencies than insulated bipolar transistors (IGBTs). The specific MOSFET, described in Table 3, utilizes SiC technology, which offers higher efficiency and temperature withstand than Si technology.

Table 3 Semiconductor devices selected as $\mathrm{Q}_{1}$ for analysis

| Technology | Manufacturer | Part Number | R $_{\text {DS(on) }}$ |
| :---: | :--- | :--- | :--- |
| SiC MOSFET | CREE | C2M0280120D | $280 \mathrm{~m} \Omega$ |

Figure 9 shows the $\mathrm{V}_{\mathrm{DS}}(\mathrm{t})$ plot for the design using parameters from Tables 1 and 2 and the SiC MOSFET manufactured by CREE with part number C2M0280120D. The simulation showed $\mathrm{P}_{\mathrm{o}}$ approximately equal to 162 W and under not ideal switching conditions.


Figure 9 Simulation of design using components values in Tables 1 and 2 and $R_{D S(o n)}=280 \mathrm{~m} \Omega$

### 3.6TUNING OF DESIGN BASED ON KAZIMIERCZUK'S EQUATIONS

Components determined and listed in Table 2 were tuned to achieve optimum conditions using simulation. While the target was to ultimately maintain $\mathrm{R}=100 \Omega$ and $\mathrm{Q}_{\mathrm{L}}=6$, these parameters were adjusted to achieve damping and output power as required for ZVS and ZDS. Table 4 shows the component values selected from tuning based on simulation analysis. The resultant ZVS and ZDS plots from this improved design are shown in Figure 10. The following basic guidelines were followed until the optimum design goals were reasonably achieved:

- When the $\mathrm{Q}_{1}$ voltage is below zero volts at the moment of $\mathrm{Q}_{1}$ turn-on, increase $\mathrm{C}_{1}$ or increase R.
- When the $\mathrm{Q}_{1}$ voltage is above zero volts at the moment of $\mathrm{Q}_{1}$ turn-on, decrease $\mathrm{C}_{1}$ or decrease R .
- When more $P_{O}$ is required increase $Q_{L}$ or make $f_{r, C o n}$ and $f_{r, C o f f}$ closer to $f_{S W}$.
- When less $P_{o}$ is required decrease $Q_{L}$ or make $f_{r, C o n}$ and $f_{r, C o f f}$ farther from $f_{s w}$.

Table 4 Design values after tuning based on simulation analysis

| R | $105.78 \Omega$ |
| :--- | :--- |
| $\mathrm{C}_{1}$ | 360 pF |
| L | $96 \mu \mathrm{H}$ |
| C | 360 pF |



Figure 10 Using components designed listed in Table 4, $\mathrm{P}_{\mathrm{O}}=154.56 \mathrm{~W}$

## CHAPTER 4

## STEADY STATE LOAD ANALYSIS USING SIMULATION

### 4.1 ASSUMPTIONS

Key assumptions used for the simulation analysis were the following:

1) $L_{F}$ is finite and input current ripple exists.
2) Internal resistance of $Q_{1}$ is considered and a non-zero value.
3) No parasitic resistances exist throughout the circuit.
4) Turn-on and turn-off times of switching device are neglected and thus $Q_{1}$ turns on and off instantly.
5) $\mathrm{C}_{1}$ is constant and not influenced by other parameters.
6) Output power is calculated by using the instantaneous load voltage and load current multiplied together and averaged over one cycle.

### 4.2 METHODOLOGY

Each simulation was performed using final design values shown in Table 5. The $\mathrm{R}_{\mathrm{DS}(\mathrm{on})}$, $\mathrm{L}_{1}$, and R component values varied for each simulation. Two different Si and SiC MOSFET switching device models shown in Table 6 were used to determine the effect of $\mathrm{R}_{\mathrm{DS}(\text { on })}$ on the load and ZVS and ZDS performance. The load impedance required for ZVS and ZDS operation for each load and device combination were determined by modifying the load parameters, $\mathrm{L}_{1}$ and R , within the simulation until the optimum performance was found. The $\mathrm{P}_{\mathrm{O}}, \mathrm{V}_{\mathrm{O}}, \mathrm{I}_{\mathrm{O}}$, and efficiency values for each load and device combination were calculated. The load consisted of impedance values in the range of $20 \Omega$ to $200 \Omega$, in increments of $10 \Omega$. Load parameters, R and $\mathrm{L}_{1}$, required
to achieve each impedance value in range of $20 \Omega$ and $200 \Omega$ were determined by using Equations (2.3.2) and (2.3.4).

Table 5 Component values used in each simulation

| $\mathrm{V}_{\mathrm{DD}}$ | 208 V |
| :--- | :--- |
| $\mathrm{f}_{\mathrm{SW}}$ | 1 MHz |
| D | 0.45 |
| $\mathrm{~L}_{\mathrm{F}}$ | 1.5 mH |
| $\mathrm{C}_{1}$ | 360 pF |
| L | $96 \mu \mathrm{H}$ |
| C | 360 pF |

Table 6 Semiconductor devices selected as $\mathrm{Q}_{1}$ for analysis

| Technology | Manufacturer | Part Number | RDS(on) $^{\text {Si MOSFET }}$ |
| :--- | :--- | :--- | :--- |
| Microsemi Inc. | APT7M120B | $1.5 \Omega$ |  |
| SiC |  |  |  |
| MOSFET | CREE Inc. | C2M0280120D | $280 \mathrm{~m} \Omega$ |

### 4.3 RESULTS

Table 7 lists the load impedances required for ZVS and ZDS for 1.0 and 0.8 power factor loads for both of the Si and SiC MOSFETs. The ZVS and ZDS performance of the SiC MOSFET for 1.0 and 0.8 power factor loads is shown in Figure 11. Figures 12 and 13 demonstrate the output active power, conversion efficiency, load voltage and load current for 1.0 and 0.8 power factor loads, respectively.

Table 7 Z $_{\text {OPT }}$ for various switch types and load power factors determined by simulation

| Switch <br> Type | Power <br> Factor | Zopt <br> $(\boldsymbol{\Omega})$ |
| :--- | :--- | :--- |
| Si | 1.0 | 105.3 |
| SiC | 1.0 | 105.9 |
| Si | 0.8 | 119.1 |
| SiC | 0.8 | 119.5 |




Figure 11 ZVS and ZDS plots for 1.0 and 0.8 power factors loads respective to top and bottom charts


Figure 12 Simulation results for 1.0 power factor load


Figure 13 Simulation results for 0.8 power factor load

### 4.4 ANALYSIS

Figure 11 shows the resonant frequency increases for a 0.8 power factor load compared to a 1.0 power factor load as expected based on Equations (2.2.2) and (2.2.4) for $\mathrm{f}_{\mathrm{r}, \mathrm{Con}}$ and $\mathrm{f}_{\mathrm{r}, \text { Coff }}$. ZVS and ZDS conditions for the 0.8 power factor load was achieved by increasing the impedance to increase dampening of the load waveforms (Table 7).

Figures 12 and 13 show both the 1.0 and 0.8 power factor loads have the highest efficiency at and near $Z_{\text {оPт }}$. However, maximum output capability shown in these figures are not exactly at $Z_{\text {OPT }}$. For 1.0 and 0.8 power factor loads the maximum output power is at approximately $100 \Omega$ impedance. Simulations with load impedances equal to or less than $20 \Omega$ did not achieve steady state performance due to too little dampening and were excluded from the analysis.

Figure 12 shows characteristics of its associated circuits being more underdamped than those shown in Figure 13. This is as expected because the added inductance, $L_{1}$, for the power factor 0.8 loads increase the resonant frequency to be further from fsw causing less resonance. The result is almost twice the peak power for the power factor 1.0 load compared to the power factor 0.8 load, but with a higher rate of change of power output capability during variation from $Z_{\text {Opt }}$.

Figure 12 shows the largest difference in conversion efficiency between the Si and SiC models is about 1.14 percent at $100 \Omega$ while Figure 13 shows the largest difference in conversion efficiency between Si and SiC models is about 0.93 percent at $100 \Omega$. These results show the influence of $\mathrm{R}_{\mathrm{DS}(\text { on })}$ on conversion efficiency is limited and may reasonably be assumed negligible for all considerations except circuit efficiency in order to simplify mathematical analysis.

In the range of $80 \Omega$ to $140 \Omega$ the power factor 1.0 load remains within five percent of the rated output power and with efficiency greater than 97.1 percent. Above $140 \Omega$ the efficiency and output power decrease at a high rate. Below $80 \Omega$ the output power decreases at a high rate while the efficiency remains above 96.7 percent. In summary, in specific load impedance regions offer reasonable output power and efficiency performance.

In the range of $72 \Omega$ to $150 \Omega$ the power factor 0.8 load remains within five percent of one-half the rated output power and with efficiency greater than 95 percent. Below $72 \Omega$ the output power decreases at a moderate rate while efficiency remains at or above 95 percent. Above $150 \Omega$ the power output decreases at a slow rate while efficiency decreases at a high rate. In summary, for this design the 0.8 power factor load operates reasonably well in the load region $72 \Omega$ to $150 \Omega$ at one-half the designed output power.

Both of the 1.0 and 0.8 power factor loads lack voltage regulation. Consequently, as the load impedance increases the current decreases while the voltage increases (Figures 12 and 13). For WPT applications commonly the received signal is converted to DC and a DC to DC voltage regulator is utilized for end of use voltage control. Further evaluation of voltage regulation at load side is out of the scope of this work.

## CHAPTER 5

## STEADY STATE LOAD ANALYSIS USING MATHEMATICS

### 5.1 ASSUMPTIONS

Key assumptions used for the mathematical analysis were the following [23]:

1) $L_{F}$ is large enough to neglect its current ripple.
2) Internal resistance of $L_{F}$ is zero and the $D C$ voltage drop across $L_{F}$ is zero.
3) $Q_{L}$ of the LC resonant tank is high enough so that the output current can be considered as a pure sinusoidal waveform.
4) Load resistance includes parasitic resistances of the resonant circuit such that the resonant circuit can be considered as a pure reactance.
5) Internal resistance of the switching device is neglected and equal to zero.
6) $Q_{1}$ is an ideal switching device.
7) $\mathrm{C}_{1}$ is constant and not influenced by other parameters.

### 5.2 EQUATIONS

Equations from [23] were used for the steady-state load analysis using mathematics.

$$
\begin{gather*}
i_{\mathrm{O}}(\mathrm{t})=I_{O} \sin (\omega t+\emptyset)  \tag{5.2.1}\\
i_{S}(\mathrm{t})=I_{D D}-I_{O} \sin (\omega t+\emptyset)  \tag{5.2.2}\\
V_{S}(t)=\frac{1}{\omega C_{1}}\left[I_{D D} \omega t+I_{O} \cos (\omega t+\varphi)-I_{O} \cos \varphi\right] \tag{5.2.3}
\end{gather*}
$$

$$
\begin{align*}
\emptyset=-\tan ^{-1}[ & \left(\frac{1}{4} \cos 4 \pi D_{1}-\cos 2 \pi D_{1}+\pi \omega C_{1} R+\frac{3}{4}\right)\left(2 \pi D \sin 2 \pi D_{1}\right. \\
& \left.+\cos 2 \pi D_{1}-1\right) \\
& +\left(\sin 2 \pi D_{1}-\frac{1}{4} \sin 4 \pi D_{1}+\pi \omega C_{1} X-\pi D_{1}\right)\left(2 \pi D \cos 2 \pi D_{1}\right. \\
& \left.\left.-\sin 2 \pi D_{1}\right)\right] \\
& /\left[( - \frac { 1 } { 4 } \operatorname { s i n } 4 \pi D _ { 1 } - \pi \omega C _ { 1 } X + \pi D _ { 1 } ) \left(2 \pi D \sin 2 \pi D_{1}\right.\right. \\
& \left.+\cos 2 \pi D_{1}-1\right) \\
& \left.+\left(\pi \omega C_{1} R+\frac{1}{4}-\frac{1}{4} \cos 4 \pi D_{1}\right)\left(2 \pi D_{1} \cos 2 \pi D_{1}-\sin 2 \pi D_{1}\right)\right]  \tag{5.2.4}\\
I_{D D}=2 \pi \omega C_{1} & V_{D D} /\left\{2 \pi^{2} D_{1}^{2}\right. \\
& +\left[\left(\sin 2 \pi D_{1}-2 \pi D_{1}\right) \cos \emptyset\right. \\
& \left.+\left(\cos 2 \pi D_{1}-1\right) \sin \emptyset\right]\left[\left(-2 \pi D_{1} \cos 2 \pi D_{1}\right.\right. \\
& \left.\left.+\sin 2 \pi D_{1}\right) \cos \emptyset+\left(2 \pi D \sin 2 \pi D_{1}+\cos 2 \pi D_{1}-1\right) \sin \emptyset\right] \\
& /\left[\left(\frac{1}{2} \cos 4 \pi D_{1}-\cos 2 \pi D_{1}+\frac{1}{2}\right) \cos \emptyset^{2}\right. \\
& +\left(-\frac{1}{2} \sin 4 \pi D_{1}+\sin 2 \pi D_{1}\right) \sin \emptyset \cos \emptyset \\
& \left.\left.+\left(\pi \omega C_{1} R-\frac{1}{4} \cos 4 \pi D_{1}+\frac{1}{4}\right)\right]\right\}
\end{align*}
$$

$$
\begin{gather*}
I_{m}=I_{D D}\left[\left(-2 \pi D_{1} \cos 2 \pi D_{1}+\sin 2 \pi D_{1}\right) \cos \emptyset\right. \\
\\
\left.+\left(2 \pi D \sin 2 \pi D_{1}+\cos 2 \pi D_{1}-1\right) \sin \emptyset\right] \\
\\
\hline
\end{gather*}
$$

### 5.3 METHODOLOGY

Each mathematical calculation for $\mathrm{P}_{\mathrm{o}}, \mathrm{I}$, and $\mathrm{V}_{\mathrm{S}}$ was performed using component values shown in Table 5 to allow comparison of the mathematical results to the simulation analysis. Similar to the simulation analysis, the $\mathrm{L}_{1}$ and R component values were calculated according to Equations (2.7.2) and (2.7.4) for these simulations. Between impedance values $20 \Omega$ and $200 \Omega$ and in increments of $10 \Omega$ the mathematical calculation was used to record the $\mathrm{P}_{\mathrm{o}}, \mathrm{V}_{\mathrm{O}}, \mathrm{I}_{\mathrm{o}}$, and efficiency values for each 1.0 and 0.8 power factor load. Equation (5.2.3) was used to plot $\mathrm{V}_{\mathrm{S}}$ for one cycle in aim to find the $\mathrm{Z}_{\mathrm{OPT}}$ for 1.0 and 0.8 power factor loads using mathematical analysis.

Table 8 Component values used in each mathematical simulation

| $\mathrm{V}_{\mathrm{DD}}$ | 208 V |
| :--- | :--- |
| $\mathrm{f}_{\mathrm{sw}}$ | 1 MHz |
| D | 0.45 |
| $\mathrm{C}_{1}$ | 360 pF |
| L | $96 \mu \mathrm{H}$ |
| C | 360 pF |

### 5.4 RESULTS

ZVS and ZDS performance using mathematical analysis was unable to be confirmed by using Equation (5.2.3) for any of the impedance values in the range of $20 \Omega$ to $200 \Omega$ and for both 1.0 and 0.8 power factor loads. Figures 14 and 15 compare the output active power and load current for 1.0 power factor and 0.8 power factor loads, respectively, to the simulation results.


Figure 14 Comparison of math results to simulation results for 1.0 power factor load


Figure 15 Comparison of math results to simulation results for 0.8 power factor load

### 5.5ANALYSIS

Analysis from Section 4.4 show the effect of $\mathrm{R}_{\mathrm{DS}(\mathrm{on})}$ less than or equal to $1.5 \Omega$ is insignificant on the ECE of the class-E resonant inverter. $\mathrm{L}_{\mathrm{F}}$ is designed to maintain ripple current below five percent. These concepts justify simplification of the mathematical analysis significantly by neglecting $\mathrm{R}_{\mathrm{DS}(o n)}$ and assuming no input current ripple.

Figures 14 and 15 show close agreement between the simulated and calculated values of Io. The difference between the simulated and calculated output power is partly because the mathematical analysis neglected the effects of the anti-parallel diode to $\mathrm{Q}_{1}$ [23]. This difference is also caused by neglecting the phase difference between Io and $V_{O}$ when calculating the output power in the mathematical analysis. Conversely, the simulation analysis did not neglect the phase difference when computing the power output. Therefore, more load reactance results in increased error in output power calculations between the simulation and mathematical analysis. This explains why more error exists in the results of 0.8 power factor load than the 1.0 power factor load. Also, it explains why the calculated output power is approximately 20 W more than the simulated output power for the 0.8 power factor load for impedances $20 \Omega$ to $200 \Omega$.

Another key reason for the disparity between simulated and calculated output power is the presence of two different resonant frequencies, $\mathrm{f}_{\mathrm{r}, \mathrm{Con}}$ and $\mathrm{f}_{\mathrm{r}, \text { Coff }}$, existing during the on and off states of $\mathrm{Q}_{1}$. As a result, io is not a pure sinusoidal waveform in practice. The RMS value made in both the simulation and the mathematical analysis are an approximation. The power output in simulation analysis considers the impurity of the output current while the mathematical analysis does not. During the off-state, io should be in resonance at the frequency of $\mathrm{f}_{\mathrm{r}, \text { Coff, }}$, but instead, at $f_{\text {SW }}$ due to assumption. Because $f_{r, \text { Coff }}$ is greater than $f_{S W}$, more impedance is needed to dampen $\mathrm{V}_{\mathrm{DS}}$ in order to achieve ZVS and ZDS.

Ideally, the resonant frequencies, $\mathrm{f}_{\mathrm{r}, \mathrm{Con}}$ and $\mathrm{f}_{\mathrm{r}, \text { Coff }}$, should be close to each other to achieve closely-pure sinusoidal waveform at load. This would improve power quality, reduce noise and increase conversion efficiency.

## CHAPTER 6

## LOAD ANALYSIS USING EXPERIMENTATION

### 6.1 METHODOLOGY

Each experiment utilized the same key components on the test bed including control driver, voltage supply, MOSFET, choke inductor, and Schottky diode. A Schottky diode was used in parallel to the MOSFET to allow fast recovery of reverse currents to bypass the MOSFET. Experiments differed from each other by using unique passive components (Table 9). Tuning of the switching frequency and $\mathrm{C}, \mathrm{R}, \mathrm{L}$, and $\mathrm{C}_{1}$ component values was performed until ZVS and ZDS conditions for $\mathrm{Q}_{1}$ were met and recorded as Experiments \#1 and \#2. Experiments \#3 through \#10 were performed to analyze varying resistive and inductive load assignments from ideal ZVS and ZDS conditions. Each experiment is numbered on Table 9 and corresponds to a figure showing the experiment's associated $V_{D S}(t)$ and $V_{O}(t)$ waveforms.

Figure 16 shows a picture of the test bed established to perform experimental testing. It shows the manufactured printed circuit board with associated circuit components mounted to it, signal generator for pulse width modulation, DC power supply for control, DC power supply for power, and an oscilloscope. A custom inductor and resistor bank on bread board is shown to allow easy modification of the load. Appendix A elaborates on the hardware setup used for these experiments.


Figure 16 Test-bed of a 150 W class-E resonant inverter prototype

### 6.2 ASSUMPTIONS

Due to the lack of available voltage probes rated for 1200 V , it was assumed that a reduction in supply voltage would not affect the load impedance at which ZVS and ZDS performance was achieved. Simulation was used to validate this assumption. Also, due to limited available hardware in the lab the output power was assumed to be according to Equation (6.2.1).

$$
\begin{equation*}
P_{O}=\frac{V_{O}{ }^{2}}{2 \mathrm{R}} \tag{6.2.1}
\end{equation*}
$$

### 6.3 RESULTS

Table 9 Component parameters used for each experiment

| Experiment <br> $\#$ | $\mathbf{L}_{\mathbf{F}}$ <br> $(\mathbf{m H})$ | $\mathbf{C}$ <br> $(\mathbf{n F})$ | $\mathbf{R}$ <br> $(\mathbf{\Omega})$ | $\mathbf{L}$ <br> $(\boldsymbol{\mu} \mathbf{H})$ | $\mathbf{C}_{\mathbf{1}}$ <br> $(\mathbf{p F})$ | Duty <br> $\mathbf{C y c l e}$ | $\mathbf{f}_{\mathbf{S W}}$ <br> $(\mathbf{k H z})$ | $\mathbf{V}_{\mathbf{D D}}$ <br> $(\mathbf{V})$ |
| :--- | :--- | :--- | :--- | :--- | :--- | :--- | :--- | :--- |
| 1 | 1.5 | 17.7 | 50 | 50 | 0 | 0.45 | 850 | 40.2 |
| 2 | 1.5 | 12.1 | 50 | 66 | 0 | 0.45 | 850 | 40.2 |
| 3 | 1.5 | 23.12 | 100 | 50 | 0 | 0.45 | 850 | 40.2 |
| 4 | 1.5 | 23.12 | 150 | 50 | 0 | 0.45 | 850 | 40.2 |
| 5 | 1.5 | 23.12 | 200 | 50 | 0 | 0.45 | 850 | 40.2 |
| 6 | 1.5 | 23.12 | 50 | 50 | 0 | 0.45 | 850 | 40.2 |
| 7 | 1.5 | 23.12 | 400 | 50 | 0 | 0.45 | 850 | 40.2 |
| 8 | 1.5 | 23.12 | 100 | 14.74 | 0 | 0.45 | 850 | 40.2 |
| 9 | 1.5 | 23.12 | 300 | 42.2 | 0 | 0.45 | 850 | 40.2 |
| 10 | 1.5 | 23.12 | 300 | 42.2 | 0 | 0.45 | 850 | 40.2 |




Figure $17 \mathrm{~V}_{\mathrm{DS}}(\mathrm{t})$ and $\mathrm{V}_{\mathrm{O}}(\mathrm{t})$ Waveforms from Experiment \#1


Figure $18 V_{D S}(t)$ and $V_{O}(t)$ Waveforms from Experiment \#2


Figure $19 \mathrm{~V}_{\mathrm{DS}}(\mathrm{t})$ and $\mathrm{V}_{\mathrm{O}}(\mathrm{t})$ waveforms from Experiment \#3


Figure $20 \mathrm{~V}_{\mathrm{DS}}(\mathrm{t})$ and $\mathrm{V}_{\mathrm{O}}(\mathrm{t})$ waveforms from Experiment \#4


Figure $21 \mathrm{~V}_{\mathrm{DS}}(\mathrm{t})$ and $\mathrm{V}_{\mathrm{O}}(\mathrm{t})$ waveforms from Experiment \#5


Figure $22 \mathrm{~V}_{\mathrm{DS}}(\mathrm{t})$ and $\mathrm{V}_{\mathrm{O}}(\mathrm{t})$ waveforms from Experiment \#6


Figure $23 \mathrm{~V}_{\mathrm{DS}}(\mathrm{t})$ and $\mathrm{V}_{\mathrm{O}}(\mathrm{t})$ waveforms from Experiment \#7


Figure $24 \mathrm{~V}_{\mathrm{DS}}(\mathrm{t})$ and $\mathrm{V}_{\mathrm{O}}(\mathrm{t})$ waveforms from Experiment \#8


Figure $25 \mathrm{~V}_{\mathrm{DS}}(\mathrm{t})$ and $\mathrm{V}_{\mathrm{O}}(\mathrm{t})$ waveforms from Experiment \#9


Figure $26 V_{D S}(t)$ and $V_{O}(t)$ waveforms from Experiment \#10

Figure 27 Conversion efficiency of class-E prototype with load resistances $100 \Omega, 150 \Omega, 200 \Omega$, and $400 \Omega$ for Experiments \#3, \#4, \#5, and \#7, respectively

### 6.4 ANALYSIS

Achieving ZVS and ZDS operation of $\mathrm{Q}_{1}$ during experimentation required modifying switching frequency, load impedance, resonant tank parameters, and shunt capacitance from design values. ZVS and ZDS performance of $\mathrm{Q}_{1}$ was achieved in Experiments \#1 and \#2 as shown
in Figures 17 and 18, respectively. The optimum design point, Z Zopt, where ZVS and ZDS occurred for the experimental test differed from the simulated and calculated results because of the parasitic effects in the circuit dampened the resonance and the nonlinear shunt capacitance formed from the MOSFET and Schottky diode. In order to achieve ZVS and ZDS the switching frequency had to be reduced from 1 MHz to 850 kHz . The resonant frequency, $\mathrm{f}_{\mathrm{r}, \text { Coff }}$, generated by the resonant tank reduced the design from 1.2107 MHz to a calculated value of 161.8 kHz . By reducing $\mathrm{f}_{\text {Sw }}$ and $\mathrm{f}_{\mathrm{r}, \text { Coff }}$ less parasitic influence on the resonant waveforms allowed ZVS and ZDS operation to be achieved. While the calculated resonant frequency is 161.8 kHz , fsw is equal to 850 kHz and it is therefore unlikely that the calculated resonant frequency is accurate on the test bed and in reality much higher than 161.8 kHz .

Experiments \#3 through \#10 focused on observation of load waveforms varying from this optimum performance. Also, the ECE of load impedances $100 \Omega, 150 \Omega, 200 \Omega$, and $400 \Omega$ were analyzed using Equation (6.2.1) to calculate $\mathrm{P}_{\mathrm{O}}$ and information from the DC power supply to calculate input power. Vo plots shown in all experiments (see Figures 17 through 26) clearly show two different resonant frequencies formed for on and off cycles of $\mathrm{Q}_{1}$. As expected, loads with more impedance increased circuit dampening and resulted in a loss of conversion efficiency as described in Figure 27 for experiments utilizing load impedances of $100 \Omega, 150 \Omega, 200 \Omega$, and $400 \Omega$ in Figures 19, 20, 21, and 23, respectively. Because of parasitic influence and assumptions used for output power calculation which neglected phase difference between $\mathrm{V}_{\mathrm{O}}$ and $\mathrm{I}_{\mathrm{O}}$, the output power results are significantly different from the simulation and mathematical results. However, these experiments show important considerations that should be used in future research and experimentation.

## CHAPTER 7

## CONCLUSIONS AND FUTURE WORK

The simulation and mathematical results show that the presented class-E resonant inverter design offers high ECE and reasonable performance during load variation within a certain load region. Better load variation performance requires a lower $\mathrm{Q}_{\mathrm{L}}$ and lower overall efficiency and output power capability. Load impedance for ZVS and ZDS conditions is unique and any load variation causes these conditions to be lost. Switch device internal resistance when less than $1.5 \Omega$ has only substantial effect on the ECE and not load current or voltage. This concept establishes the reasonable assumption for the mathematical analysis to neglect the internal resistance of the switching device. Similar output power performance between the simulation and mathematical models were achieved. Discrepancies between these models were caused by the additional assumptions used in the mathematical model. These notable assumptions include neglecting the effects of the antiparallel diode intrinsic to $\mathrm{Q}_{1}$, neglecting phase difference between $\mathrm{I}_{0}$ and $\mathrm{V}_{0}$ when calculating $\mathrm{P}_{\mathrm{o}}$, and assuming the load current consists of only the frequency of fsw and not the two resonant frequencies $\mathrm{f}_{\mathrm{r} C o n}$ and $\mathrm{f}_{\mathrm{r} C o f f}$. Experimental results showed minor comparison between the simulation and mathematical models. This was mainly due simulation and mathematical assumptions that did not consider parasitic effects and nonlinear shunt capacitance intrinsic to the utilized MOSFET and Schottky diode. Experimental results clearly show the two different resonant frequencies $f_{r, C o n}$ and $f_{r, C o f f}$ causing impurity and a DC offset of the load voltage waveform.

Future simulation and mathematical models should have the nonlinear shunt capacitance of the switching component and other parasitic impedances analyzed. In addition, the behavior of the resonant tank should be monitored and studied. These models would be very complex and involve high order differential equations. However, by having these advanced models made an
experimental test bed can be established which more closely resembles the simulation and mathematical models. Mathematical assumptions should not neglect a load current comprised of $f_{r, C o n}$ and $f_{r}$,Coff. Experimental test beds should aim to select switching devices with a minimum amount of intrinsic capacitance to avoid nonlinear shunt capacitance.

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## APPENDIXES

## A. EXPERIMENT HARDWARE SETUP

The bill of material for purchasing parts used on the PCB are shown in Table 10. Various capacitors and an adjustable inductor were purchased to allow different experiments outlined in Table 9.

Table 10 Bill of material for test bed

| Component | Quantity | MFG Part Number | Manufacturer |
| :---: | :---: | :---: | :---: |
| Capacitor | 2 | DEHR33F181KC3B | Murata Electronics North America |
| Capacitor | 5 | DEA1X3F101JA3B | Murata Electronics North America |
| Capacitor | 2 | DEA1X3F470JC3B | Murata Electronics North America |
| Capacitor | 1 | DEA1X3F390JC3B | Murata Electronics North America |
| Capacitor | 2 | DEA1X3F330JC3B | Murata Electronics North America |
| Capacitor | 1 | DEA1X3F270JC3B | Murata Electronics North America |
| Capacitor | 1 | DEA1X3F180JCDB | Murata Electronics North America |
| Capacitor | 3 | DEA1X3F150JCDB | Murata Electronics North America |
| Capacitor | 1 | DEA1X3F220JCDB | Murata Electronics North America |
| Capacitor | 3 | DEA1X3F100JCDB | Murata Electronics North America |
| E Type Magnetic Core | 1 | 0F43007EC | Magnetics Inc. |
| MOSFET | 2 | C2M0280120D | CREE |
| Choke Inductor | 1 | AIRD-03-152K | Abracon LLC |
| Driver | 1 | FAN3111ESX | Fairchild Semiconductor |
| DB9 Connector | 1 | A-DF-09-A/KG-T2S | Assmann <br> Components WSW |
| Two Position Terminal Block | 2 | 1776275-2 | TE Connectivity AMP Connectors |
| Load Resistance | 2 | PF2472-200RF1 | Riedon |
| Load Resistance | 2 | PF2472-100RF1 | Riedon |
| Load Resistance | 2 | PF2472-50RF1 | Riedon |


| LED Diode | 1 | 5501304 F | Dialight |
| :--- | :--- | :--- | :--- |
| LED Resistor | 1 | CMF55102K00FHEB | Vishay Dale |
| Fuse | 1 | BK/PCE-5-R | Eaton |
| Schottky Diode | 1 | GP2D005A120A | Global <br> Technologies Group |
| Hex Stand Off | 1 | 25505 | Keystone Electronics |
| Nut for Hex Stand Off | 1 | 4688 | Keystone Electronics |

CadSoft Eagle Professional 7.6.0 software was used to design the PCB using the components from Table 10. The Eagle CAD schematic file (Figure 28) was used to generate the board file (Figure 29). The CAM Processor feature of the Eagle software was used to generate files from the board file that could be transferred to gerber files using the GerberLogix software. These gerber files were sent to and used by a local manufacturer to create the PCB.

The inductor, L , was custom constructed by turning magnetic core wire around a type E magnetic core using manufacturer of the magnetic cores guidelines for design. A LCR meter was used to validate passive inductor and capacitor elements met manufacturer listings. A multimeter was used to validate resistor values met manufacturer listings. A waveform test circuit was constructed to validate the performance of the MOSFET.

Signals identified in the schematic (Figure 28) are identified in Table 11. A high power AC to DC power supply was used to provide the supply voltage. A traditional lab DC power supply was used to supply the input and reference voltages for the driver circuit. For all experiments listed in Table 9 an input voltage of +12 V and a reference voltage of +3 V was used for the gate driver. A function generator was used to provide the square wave pulse width modulation (PWM) signal to the gate driver. For all experiments listed in Table 9 the amplitude of the PWM signal was +/- 3 V . The PCB (Figure 29) consists of two layers including the top layer for control and power and the bottom layer for grounding. At higher frequencies parasitic impedance noise becomes more problematic for design. Components were spaced as closely as
possible on the PCB to reduce the effects of parasitic noise. The top layer area was maximized while allowing power connections to reduce the electromagnetic interference related to high frequency switching operation.


Figure 28 Eagle CAD PCB schematic
Table 11 Signal list for schematic in Figure 28

| Signal | Function |
| :--- | :--- |
| U\$10G\$1 | + Supply Voltage |
| U\$10G\$2 | - Supply Voltage |
| U\$17G\$1 | + VREF |
| U\$17G\$2 | - VREF |
| P\$1 | + PWM |
| P\$6 | - PWM |



Figure 29 Eagle CAD two layer PCB board file

## VITA

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